

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Keun-Kyu Song, et al. )  
Serial No.: 10/538,511 ) Group Art Unit:  
Filed: June 9, 2005 ) 2812  
For: STRIPPING COMPOSITION FOR )  
REMOVING A PHOTORESIST AND )  
METHOD OF MANUFACTURING TFT )  
SUBSTRATE FOR A LIQUID CRYSTAL )  
DISPLAY DEVICE USING THE SAME )

**RESPONSE TO RESTRICTION REQUIREMENT**

**Via EFS**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the restriction requirement mailed on August 21, 2007, the Applicants submit the following election of invention pursuant to 37 CFR 1.142 or species pursuant to 37 CFR 1.146 for further prosecution on the merits:

**Election:**

The Applicants hereby elect, without traverse, the invention of Group II, claims 4-18, drawn to a method for forming a photoresist pattern, and classified in class 438, subclass 689.

## REMARKS

Claims 1-18 are pending in the present application, and are subject to a Restriction requirement of the invention or species listed in the requirement.

In response to the Examiner's Restriction, Applicants hereby elect prosecution of Group II, claims 4-18, drawn to a method for forming a photoresist pattern, without traverse. These elections are being made without prejudice to Applicants' rights with respect to the unelected claims or species, including the right to file divisional application(s) thereon.

If the Examiner has any questions as to this response, the undersigned is available for a telephone conference at the number below.

If there are any additional charges with respect to this Response or otherwise, please charge them to Deposit Account No. 06-1130.

Respectfully submitted,

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